

Comparative Performance of sCMOS and UV-Sensitive EMCCD Cameras for Advanced UV Imaging and Spectroscopy

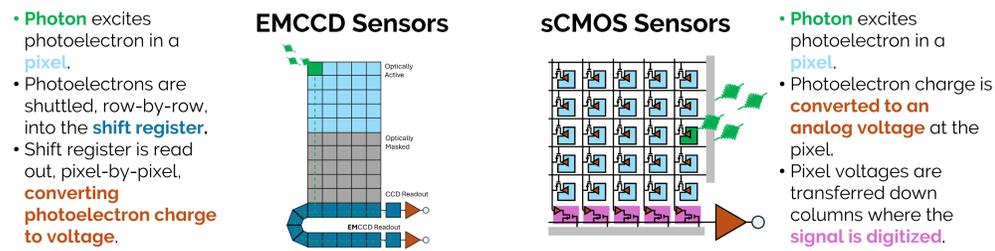


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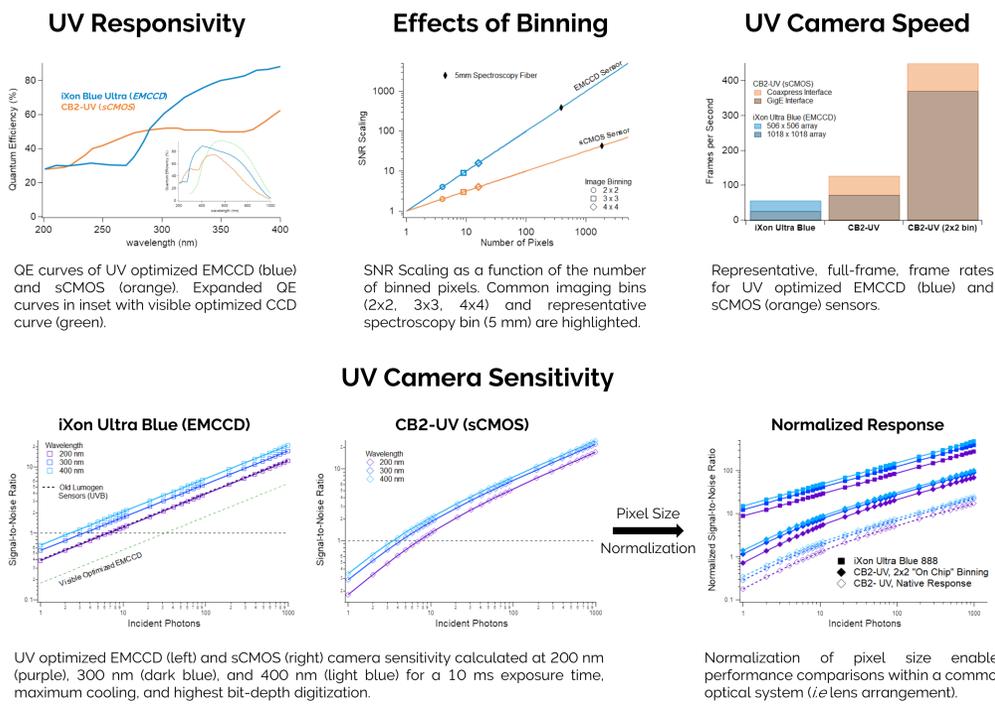
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Abstract. High-sensitivity ultraviolet (UV) imaging and spectroscopy are essential for emerging applications such as optical characterization of high-bandgap semiconductors, photolithographic mask inspection, extreme UV (EUV) light source diagnostics, UV Raman spectroscopy for chemical analysis, and plasma dynamics imaging for fusion research. These fields demand detectors with exceptional quantum efficiency (QE), low noise, and high temporal resolution in the EUV-UV range (10–400 nm). This study employs a comprehensive approach, integrating experimental measurements and simulated data to evaluate the performance of various UV-sensitive EMCCD, CCD, and sCMOS architectures across a range of cutting-edge applications.

EMCCD and sCMOS Camera Readout Architecture



Performance Characteristics of UV sCMOS and EMCCD Technologies



Implementation of UV Optimized sCMOS and EMCCD Technologies

Environmental Monitoring of Gas Emissions

Emissions from industrial sites, vehicles, and electricity heat production sites, to name a few, may not always be detectable in visible wavelength bands. For example, the emission of SO₂ from crude oil combustion can be detected in the UV when it is otherwise invisible to the naked eye or machine vision cameras.¹

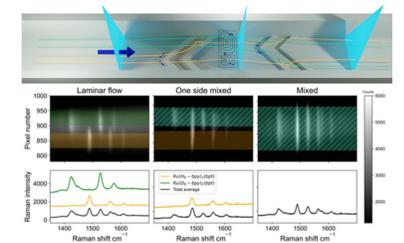
With a f/2.8 100 mm objective the CB2-UV sCMOS was used to detect SO₂ from an industrial chimney (left) while the emissions go unnoticed when imaged using a visible wavelength camera (right).



High Fidelity Spectroscopy and Microspectroscopy

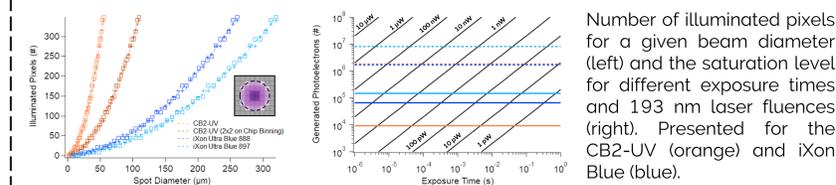
Resulting from their pixel level readout architecture, UV optimized sCMOS cameras show great promise to reduce artifacts (e.g. smearing, blooming) and enable high fidelity microspectroscopy experiments.

Concept is presented (right) for visible Raman microspectroscopy experiments of a highly dynamic microfluidic mixing system.² Such a system can be adapted to UV Raman for studying biological complexes, material analysis, and for identifying explosives and chemical agents.



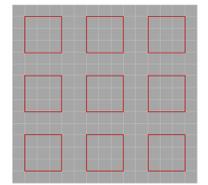
Imaging and Beam Profiling for the Semiconductor Industry

As EUV light sources continue to be developed, UV light sources remain a common fixture in semiconductor photolithography and metrology systems (ex. 193 nm). UV optimized sCMOS and EMCCD cameras are powerful tools to sample small features at and extend the "effective dynamic range" through fast image acquisition.



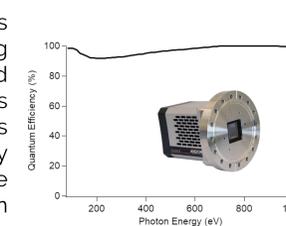
Wavefront Sensing and Adaptive Optics

Adaptive Optics (AO) systems are used to correct for atmospheric distortions to incoming wavefronts. Some AO systems rely on laser guide stars with wavelengths outside the wavelength window of the primary observation camera. The third and fourth harmonics of Nd:YAG lasers (355 nm and 266 nm, respectively) are perfectly tuned with the CB2-UV's QE curve. The multi-windowing function (illustrated right) and 2 x 2 on-chip binning further optimize the sensor for flexible readout operation for Shack-Hartman wave front sensing. With coaxpress data interface, low latencies also optimize this camera's function for AO applications.



"Moving to the Extremes" – EUV sCMOS Technology

Similar in the VUV and DUV regions, recent innovations in EUV sCMOS technology are delivering unprecedented opportunities for semiconductor and fusion research. As the semiconductor industry moves towards using 13.5 nm (~92 eV) and high NA lasers EUV sCMOS cameras offer unprecedented sensitivity and speed for high throughput applications. In the fusion space EUV technology enables rapid detection of impurities in fusion plasma.



Conclusions + References

UV optimized sCMOS and EMCCD cameras are well positioned to advance sensitive, low noise, imaging and spectroscopy systems requiring UV detection. From the semiconductor industry to general spectroscopy to on-sky observations, UV imaging and spectroscopy solutions can be optimized to meet experimental needs.

REFERENCES

1. F. Yaya, Ultraviolet CMOS Technology Opens a Spectrum of Possibility. *Photonics Spectra*, 2025
2. A.P. Carpenter, et al. ms-Time resolution Raman spectroscopy using sCMOS cameras. *Proceedings Volume 13348, Real-time Measurements, Rogue Phenomena, and Single-Shot Applications X*, 2025, 1334807

